

Current transient and *in-situ* AFM studies of initial growth stages of electrochemically deposited nickel cobalt hydroxide nanosheet films

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Supporting information

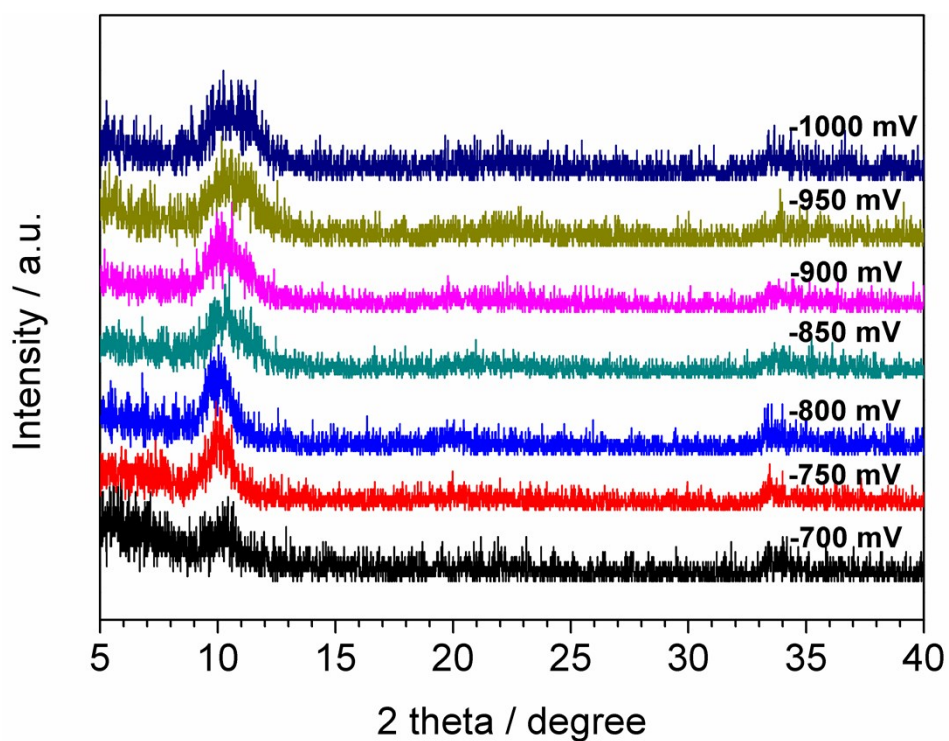


Figure S1. X-ray diffraction patterns of films deposited at different potentials.